

Product	Elements of Interest	Silicon doped titanium oxide
SOG Ti-1025	Ti, Si, O	
Refractive Index	Viscosity	Shelf Life
RI 2.0	0.90 +/- 0.25 cps	20°C 3 months 4°C 9 months

Benefits

- Excellent capacitor interlayer dielectric
- Uniform Coatings
- High index for matching optical inputs/outputs or cladding

Typical Application

Silicon doped titanium oxide is of interest for silicon doping of Ga2O3 semiconductors. Titanium glass blends are useful for their high dielectric constant and high dielectric strength. This combination is useful in making capacitors in many diverse applications. The higher index is useful for matching to many semiconductor light input or output devices. It can also be utilized, depending on processing, to give a white boundary. They may be used for wafer bonding.

- Optically transparent coating or light scattering based on processing
- UV absorbing for critical applications

Packaging

- 240ml
- 500ml
- -11
- 4 l Packaging Standard

Alternative Products

- Ti-452 Ti-100R Ti-140R Ti-1000
- Ti-1100

Alternate Elements

- Yttrium, Zirconium, Hafnium or Niobium
- Blends of two or more elements also available.
- Other elements available for compound semiconductor use.



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